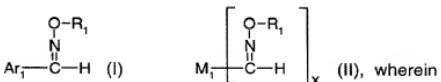


Abstract

Photosensitive compositions comprising

- (A) an alkali soluble compound;
- (B) at least one compound of formula I or II



$\text{R}_1$ , inter alia is  $\text{C}_4\text{-}\text{C}_9\text{cycloalkanoyl}$ ,  $\text{C}_3\text{-}\text{C}_{12}\text{alkenoyl}$ , or benzoyl which is unsubstituted or substituted;  $\text{Ar}_1$  is either  $\text{C}_6\text{-}\text{C}_{20}\text{aryl}$  or  $\text{C}_6\text{-}\text{C}_{20}\text{aryloyl}$  each of which is unsubstituted or substituted;  $x$  is 2 or 3;  $\text{M}_1$ , when  $x$  is 2, inter alia is a group phenylene or naphthylene, each of which optionally is substituted i.a. by  $\text{OR}_3$ ,  $\text{SR}_4$  or  $\text{NR}_5\text{R}_6$ ; or  $\text{M}_1$ , when  $x$  is 3, is a trivalent group, optionally substituted;  $\text{R}_3$  is for example hydrogen or  $\text{C}_1\text{-}\text{C}_{12}\text{alkyl}$ ;  $\text{C}_2\text{-}\text{C}_6\text{alkyl}$  which is for example substituted by  $-\text{OH}$ ,  $-\text{SH}$ ,  $-\text{CN}$ ,  $\text{C}_3\text{-}\text{C}_6\text{alkenoxy}$ , or  $-\text{OCH}_2\text{CH}_2\text{CN}$ ;  $\text{R}_4$  is for example hydrogen,  $\text{C}_1\text{-}\text{C}_{12}\text{alkyl}$ ,  $\text{C}_3\text{-}\text{C}_{12}\text{alkenyl}$ , cyclohexyl, or phenyl which is unsubstituted or substituted;  $\text{R}_5$  and  $\text{R}_6$  independently of each other inter alia are hydrogen,  $\text{C}_1\text{-}\text{C}_{12}\text{alkyl}$ ,  $\text{C}_2\text{-}\text{C}_4\text{hydroxyalkyl}$ ,  $\text{C}_2\text{-}\text{C}_{10}\text{alkoxyalkyl}$ ,  $\text{C}_3\text{-}\text{C}_5\text{alkenyl}$ ,  $\text{C}_3\text{-}\text{C}_8\text{cycloalkyl}$ , phenyl- $\text{C}_1\text{-}\text{C}_3\text{alkyl}$ ,  $\text{C}_1\text{-}\text{C}_4\text{alkanoyl}$ ,  $\text{C}_3\text{-}\text{C}_6\text{alkenoyl}$ , benzoyl or phenyl which is unsubstituted or substituted; and  
(C) a photopolymerizable compound;  
exhibit an unexpectedly good performance, in particular in photoresist technology.